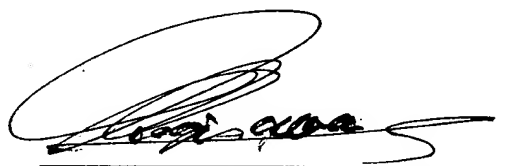


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A handwritten signature in black ink, appearing to read 'Masahiro Sugisawa', is written over a horizontal line.

Masahiro SUGISAWA

Dated: This 12th day of October, 2004.



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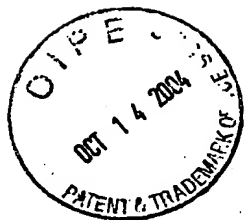
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[NAME OF THE DOCUMENT]

SPECIFICATION

[TITLE OF THE INVENTION]

OPTICAL ELEMENT AND EYEGGLASS LENS

[SCOPE OF PATENT CLAIMS]

[Claim 1] In an optical element comprised of a base material and a layer which is formed on at least one part of the surface of the base material,

the layer is substantially comprised of an inorganic material, and

the reflectance of the entire light rays in the wavelength region of from 280 to 315 nm, as well as from 420 to 680 nm on the surface of the formed layer is less than that on the surface of the base material itself.

[Claim 2] In an optical element comprised of a base material and a layer which is formed on at least one part of the surface of the base material,

the reflectance of the entire light rays in the wavelength region of from 280 to 315 nm, as well as from 420 to 680 nm on the surface of the formed layer is less than that on the surface of the base material itself, and the surface resistivity of the layer is no more than $1 \text{ M}\Omega/\text{cm}^2$.

[Claim 3] In an optical element comprised of a base material and a layer which is formed on at least one part of the surface of the base material,

the reflectance of the entire light rays in the wavelength region of from 280 to 315 nm, as well as from 420 to 680 nm on the surface of the formed layer is less than that on the surface of the base material itself, and the layer is formed on the surface which is to be the image surface of the layer.

[Claim 4] In the optical element described in claim 2 or claim 3, the layer is substantially comprised of an inorganic material.

[Claim 5] In the optical element described in claim 1 or claim 3, the layer has a surface resistivity of no more than $1 \text{ M}\Omega/\text{cm}^2$.

[Claim 6] In the optical element described in any of claim 1 through claim 5, the reflectance of the entire light rays in the wavelength region of from 280 to 315 nm, as well as from 420 to 680 nm on the surface of the formed layer is less than that on the surface of the base material itself.

[Claim 7] In the optical element described in any of claim 1 through claim 5, the reflectance of the entire light rays in the wavelength region of from 280 to 315 nm on the surface of

the formed layer is less than that on the surface of the base material itself.

[Claim 8] In the optical element described in any of claim 1 through claim 7, the layer has a luminous transmittance of at least 90 percent.

[Claim 9] In the optical element described in any of claim 1 through claim 8, the layer has a spectral transmittance of at least 98 percent to the entire light rays in the wavelength region of from 400 to 700 nm.

[Claim 10] In the optical element described in any of claim 1 through claim 9, the base material has an absorbance of at least 30 percent to some light rays in the wavelength region of from 280 to 400 nm.

[Claim 11] In the optical element described in any of claim 1 through claim 10, the base material exhibits a selective absorption characteristic which selectively absorbs some light rays in the wavelength region of from 400 to 700 nm.

[Claim 12] In the optical element described in any of claim 1 through claim 11, the base material has a luminous transmittance of no more than 75 percent.

[Claim 13] In the optical element described in any of claim 1 through claim 12, the difference in luminous reflectance

between the surface of the object side and the surface of the image side is within 1 percent.

[Claim 14] In the optical element described in any of claim 1 through claim 13, the layer is comprised of a multilayer which comprises at least one layer which absorbs at least some light rays in the wavelength region of 280 to 400 nm.

[Claim 15] In the optical element described in any of claim 1 through claim 14, the layer is comprised of a multilayer which comprises at least one electrically conductive transparent layer.

[Claim 16] In the optical element described in any of claim 1 through claim 15, the electrically conductive transparent layer is mainly comprised of indium oxide.

[Claim 17] In the optical element described in any of claim 1 through claim 16, the layer is comprised of a multilayer which comprises at least one metallic layer.

[Claim 18] In the optical element described in any of claim 1 and claim 2, and claim 4 through claim 17, the layer is formed on one surface which becomes the surface of the image side of the base material.

[Claim 19] In the optical element described in claim 3 or claim 18, an ultraviolet reflection layer is formed on the surface opposite to the surface of the object side of the

base material, and the reflectance of the entire light rays in the wavelength region of from 280 to 400 nm on the surface of the ultraviolet reflection layer formed as above is more than that on the surface of the base material itself.

[Claim 20] In the optical element described in claim 1 or claim 19, a layer is formed on the surface of the object side as well as on the surface of the image side of a base material; the difference in the wavelength which shows the peak of the spectral reflectance on the surface of the object side and the surface of the image side is to be within ± 5 percent, and the difference of the peak reflectance is to be within 1 percent.

[Claim 21] An eyeglass lens formed with the optical element described in either one of claim 1 to claim 20.

[DETAILED DESCRIPTION OF THE INVENTION]

[0001]

[TECHNICAL FIELD IN WHICH THE INVENTION BELONGS]

The present invention relates to an optical element and an eyeglass lens having a so-called reflection preventing layer (antireflection layer).

[0002]

[PRIOR ART]

It is well known that generally, ultraviolet rays exhibit strong chemical action, and occasionally degrade the durability of various substances or elements and functions associated with them.

Further, ultraviolet sun rays, which reach the surface of the Earth's surface after have been transmitted through the atmosphere, are mainly divided into deep ultraviolet rays termed "UV-B", having a wavelength in the region of from 280 to 315 nm, and near ultraviolet rays termed "UV-A", having a wavelength in the region of from 315 to 400 nm. It is noted that these ultraviolet rays exhibit high potential of injury to human eyes.

At present, widely employed as a means to minimize the entrance of these ultraviolet rays into the interior of human eyes are sunglasses (including eyeglasses) due to the ease of use.

Further, many recent eyeglass lenses, other than sunglasses, comprise UV absorbers in the lens itself and are subjected to UV absorbing coating.

[0003]

By utilizing such lenses for corrective eyeglasses, it is possible to shield from or minimize ultraviolet rays which come from the line of sight. Recently, however, it has been

verified that ultraviolet rays which come from a direction other than in the line of sight such as, for example, those which are reflected from the face surface, reflected from the back surface of the lens, and the like, result in much more injurious effects to human eyes than have been expected.

[0004]

[PROBLEM TO BE SOLVED BY THE INVENTION]

From the view of the foregoing, the present invention has been accomplished. An objective of the present invention is to provide an optical element comprising a layer capable of exhibiting a reflection preventing effect (antireflection effect) against light rays having a specified wavelength region and capable of decreasing injurious effects due to the light rays which is reflected from a surface.

Another objective of the present invention is to provide an eyeglass lens capable of decreasing the amount of ultraviolet rays which enter human eyes, as well as of effectively protecting eyes from ultraviolet rays.

[0005]

[MEANS TO SOLVE THE PROBLEMS]

The object of the present invention can be attained by employing either one of structures described in claim 1 to claim 20.

The other object of the present invention can be attained by forming an eyeglass lens with an optical element of structures described in claim 1 to claim 20.

[0006]

[FUNCTION]

By employing the optical element, reflectance on the surface of a formed layer of light rays of the specified wavelength region becomes less than that on the surface of the base material itself. As a result, the optical element results in a decrease in effects due to reflected light rays.

Further, in the case of eyeglass lenses, reflection of ultraviolet rays, especially deep ultraviolet rays which come from behind the line of sight is assuredly minimized on the back surface of the lens. As a result, the amount of ultraviolet rays, which enter the interior of the eyes, decreases.

[0007]

As previously described, the layer is substantially comprised of inorganic materials. Accordingly, the optical element results in sufficiently high surface hardness as well as high durability.

[0008]

Further, the optical element can exhibit excellent antistatic effects due to the surface resistivity of the layer of no more than $1 \text{ M}\Omega/\text{cm}^2$. Consequently, it is possible to prevent or minimize adhesion of dust on the surface of the optical element.

[0009]

Furthermore, by forming a layer on the surface which becomes the surface of the image side of the optical element, it is possible to decrease effects due to reflected light rays on the surface to an optical element, a light rays receiving element, or the like.

[0010]

[EMBODIMENTS OF THE INVENTION]

The present invention will now be detailed.

Fig. 1 is a cross-sectional view showing one example of the constitution of the optical element of the present invention.

The optical element 10 comprises a light ray transmittable plate-shaped base material 11 and a layer 12 formed on one surface of the base material 11.

[0011]

The layer 12 is preferably formed on an entire surface which becomes surface 10A of the image side of optical element 10.

"A surface of the image side (an image side surface)", as described herein, refers to the surface positioned on the side nearest an imaging system such as, for example, a sensor, CCD, eye, or the like in optical element 10. For example, in an eyeglass lens, the surface of the image side refers to the back surface of the lens positioned on the eye side. On the other hand, "a surface of the object side (an object side surface)" refers to a surface (shown as 10B in Fig. 1) from which light rays outgo. That is, the light rays come into the surface of the image side from the image side, transmits through the surface of the image side and outgo from the surface of the object side. For example, in an eyeglass lens, the surface to the object side corresponds to the front surface of the lens positioned at the opposite side of the surface of the eye side.

By forming layer 12 on the entire surface, which becomes surface 10A on the image side of optical element 10, it is possible to decrease adverse effects due to reflected light rays on the surface 10A on the image side for other

optical elements or light ray receiving elements which are arranged on the image side.

[0012]

Base material 11 itself is an optical member which exhibits functions as an optical element bearing specified optical properties such as, for example, an optical lens, a filter, a prism, a diffraction grating, a near field optical element, a light rays introducing plate, and the like.

[0013]

Listed as materials constituting base material 11 may be, for example, light rays transmitting organic materials such as acrylic resins, polycarbonate resins, norbornane based resins, polyester resins, polyethylene terephthalate resins, polyimide resins, polyethylene naphthalate resins, polyether sulfone resins, polyolefin based resins, and the like, or light rays transmitting inorganic materials such as quartz glass, soft glass, borosilicate glass, and the like.

[0014]

Layer 12 of the optical element 10 exhibits reflectance on the formed surface for the entire light rays range at wavelengths of from 280 to 315 nm as well as of from 420 to 680 nm, which is less than that on the surface of base material 11 itself. Namely, the layer 12 exhibits a

reflection preventing function to counter light rays in the specified wavelength region by being formed on base material 11. Hereunder, such a layer is called "a reflection preventing layer".

[0015]

In optical element 10, which is subjected to formation of reflection preventing layer 12, reflectance on surface 10A of the image side is sufficiently small. As a result, the amount of reflected light rays from the image side of the optical element 10 on surface 10A of the image side becomes sufficiently small.

Accordingly, adverse effects, due to reflected light rays on surface 10A of the image side against optical elements or light ray receiving elements arranged on the image side of optical element 10, are minimized.

[0016]

It is possible to constitute reflection preventing layer 12 in such a manner that a plurality of layers, in which each layer is substantially comprised of inorganic materials is laminated in the form of a multilayer.

Further, it is possible to obtain desired optical functions by forming a suitable laminated layer, employing materials having different refractive indices while taking

into account materials, thickness and other conditions of each constituent layer.

[0017]

By constituting reflection preventing layer 12 utilizing inorganic materials, it is possible to form the reflection preventing layer 12 into a very dense structure. As a result, it is possible to provide high surface hardness as well as excellent durability to optical element 10. Namely, when only one of the layers is constituted employing materials such as, for example, resins, it is impossible to obtain sufficient strength as a whole.

The number of layers, the thickness of each layer, and the order of layers in the multilayer are not particularly limited, and they may be determined based on desired optical functions.

[0018]

Inorganic materials constituting reflection preventing layer 12 are not particularly limited, and include, for example, oxides of metals such as, for example, silicon, titanium, tantalum, zirconium, cerium, hafnium, yttrium, aluminum, magnesium, praseodymium, neodymium, and the like; fluorides of metals such as magnesium, lanthanum, neodymium, calcium, cerium, aluminum, sodium, lead, yttrium, and the

like; zinc sulfide; mixture and compounds thereof, or mixtures of metals with these compounds; and the like.

[0019]

Methods for forming each layer constituting reflection preventing layer 12 are also not particularly limited. Specifically, vapor phase deposition methods, such as an evaporation method are preferred, and listed may be a vacuum deposition method, an ion plating method, a sputtering method, a CVD method, and the like.

[0020]

Base material 11 of optical element 10 is preferably comprised of materials having an absorbance of at least 30 percent for any light rays in the wavelength region of from 280 to 400 nm (being the ultraviolet region).

By utilizing such materials, it is possible to ensure minimal ultraviolet rays which come from surface 10A of the image side by reflecting the ultraviolet rays on surface 10B of the object side of optical element 10. Accordingly, in addition to the reflection preventing function of reflection preventing layer 12 of ultraviolet ray, base material 11 exhibits an ultraviolet ray absorption function. As a result, it is possible to decrease adverse effects of

ultraviolet rays on the optical elements and the like, which are arranged on the image side of optical element 10.

[0021]

Further, base material 11 can be provided with selective absorption characteristics, which selectively absorb at least a part of light in the wavelength region of from 400 to 700 nm (being the visible region).

In this case, it is possible to lower the intensity of visible light at wavelengths which result in flickering for human eyes, or which is unnecessary for sensors and the like. As a result, in addition to reflection preventing functions due to reflection preventing layer 12, base material 11 exhibits visible light absorbing functions, whereby it is possible to ensure a decrease adverse in effects due to unnecessary visible light.

[0022]

Further, a luminous transmittance of the base material 11 may be made not larger than 75%. In this case, the light ray coming from the object side of the optical element is shaded by the base material 11 and a amount of light ray emitted from the surface 10A at the image side of the optical element can be reduced. Therefore, the bad influence for

human eyes at the image side of the optical element 10 can be reduced.

[0023]

The luminous transmittance is defined in JIS T7330-15.4 and also called as "luminous transmittance factor.

The surface resistivity of reflection preventing layer 12 is preferably no more than $1 \text{ M}\Omega/\text{cm}^2$, and is more preferably no more than $200 \text{ }\Omega/\text{cm}^2$.

By adjusting the surface resistivity to no more than $1 \text{ M}\Omega/\text{cm}^2$, it is possible to provide excellent antistatic effects to optical element 10. Due to that, it is possible to minimize the adhesion of dust and the like onto the surface of optical element 10. Further, when the surface resistivity is no more than $200 \text{ }\Omega/\text{cm}^2$, it is possible to provide high electrical conductivity to the reflection preventing layer 12 and also to provide an electromagnetic wave decreasing function to optical element 10.

[0024]

The luminous transmittance of reflection preventing layer 12 itself is preferably at least 90 percent. Due to that, reflection preventing layer 12 effectively works to visually ensure sufficient brightness, and can effectively

minimize adverse effects against color reproduction properties. Further, reflection preventing layer 12 itself preferably exhibits a spectral transmittance of at least 98 percent for light (being the visible light) having a wavelength of from 400 to 700 nm. Due to that, reflection preventing layer 12 exhibits sufficiently high light transmittance whereby it is possible to provide an optical element which results in excellent color reproduction properties.

[0025]

Reflection preventing layer 12 may have a layer configuration comprising at least one layer which absorbs light rays (ultraviolet rays) having a wavelength of from 280 to 400 nm.

In this case, even though ultraviolet rays from the image side of optical element 10 are reflected on surface 10B on the object side, the ultraviolet rays are absorbed by reflection preventing layer 12. As a result, the amount of ultraviolet rays, which come from surface 10A on the image side of optical element 10 decreases, whereby it is possible to also decrease adverse effects on the optical elements and the like which are arranged on the image side of optical element 10.

[0026]

Reflection preventing layer 12 may have a layer configuration comprising at least one metallic layer.

Listed as metallic materials, which constitute the metallic layer are, for example, aluminum, chromium, platinum, silver, and mixtures thereof.

The optical layer thickness of the metallic layer is preferably from 1 to 10 nm.

When reflection preventing layer 12 has a layer configuration comprising a metallic layer, the reflection preventing layer 12 may result in an antistatic function as well as an electromagnetic wave reducing function.

[0027]

Reflection preventing layer 12 may also have a layer configuration comprising at least one electrically conductive transparent layer which exhibits light rays transmitting properties as well as electrical conductivity.

[0028]

Listed as materials which constitute the electrically conductive transparent layer are, for example, materials such as indium oxide, tin oxide, zinc oxide, and the like, and mixtures thereof, or mixtures of these materials with metals.

Listed as the metals are aluminum, chromium, platinum, gold, silver, copper, and the like.

The electrically conductive transparent layer is preferably comprised of, for example, indium oxide in a content ratio of at least 80 percent by weight; is more preferably comprised of a mixture consisting of indium oxide and tin oxide; and is most preferably comprised of a mixture consisting of indium oxide in a content ratio of at least 90 percent by weight and tin oxide in a content ratio of at most 10 percent by weight. By so doing, it is possible to assuredly adjust the electrical conductivity of the electrically conductive transparent layer to at most 200 Ω/cm^2 .

Further, the optical thickness of the electrically conductive transparent layer is preferably from 5 to 300 nm.
[0029]

When reflection preventing layer 12 has a layer configuration comprising an electrically conductive transparent layer, it is possible to provide the reflection preventing layer with an antistatic function as well as an electromagnetic wave decreasing function, and it is also possible to obtain high transmittance compared to one having a layer configuration comprising only a metallic layer.

[0030]

In the optical element 10, the difference in luminous reflectance between surface 10B of the object side and surface 10A of the image side is preferably within one percent. Due to that, it is possible to retain a good appearance without causing color difference on both sides of the optical element 10.

[0031]

The optical element of the present invention may be constituted in such a manner that an ultraviolet reflecting layer is formed on the surface (10B in the constitution of Fig. 1) of the object side so that reflectance of the entire light rays range at the wavelengths (being the ultraviolet region) of from 280 to 400 nm, is more than that on the surface of the base material itself. In this case, entrance of ultraviolet rays, which come from the object side of the optical element, into the optical element, is minimized.

[0032]

The optical element of the present invention may also be constituted in such a manner that the reflection preventing layer is formed on both of the surfaces of the object side of the base material and the surface of the image side. In this case, it is preferable that any difference in

wavelength, which shows the peak position of the spectral reflectance in the wavelength region of from 450 to 680 on the surface of the object side as well as the surface of the image side, be within ± 5 percent, and any difference in peak reflectance be within one percent. Due to that, no color difference occurs on either surface of the optical element, and the desired appearance may also be retained.

[0033]

In the optical element of the present invention, in view of an increase in the adhesive force or the surface hardness of the reflection preventing layer, a hard coat layer and a commonly known sublayer comprised of materials represented, for example, by silicone based thermohardening resins, and acryl based ultraviolet hardening resins may be provided on the surface of the base material.

Further, the employed base material may be tinted in the range which does not adversely affect light rays transmitting properties. Still further, plates and films may be stacked and laminated.

[0034]

Optical elements as above may suitably be employed as various types of optical elements in, for example, eyeglass lenses, binoculars, telescopes, microscopes, opera glasses,

head mount displays, and the like. Further, as described below, marked effects are particularly obtained when employed in eyeglass lenses.

[0035]

<Eyeglass Lens>

The eyeglass lens of the present invention is formed employing the optical element. Specifically, the eyeglass lens is comprised of lens bodies as the base materials and the reflection preventing layer formed on one surface which becomes the surface of the image side of the lens body, namely on the opposite surface of the lens on the eye side.

[0036]

When such eyeglass lenses are utilized, it is possible to effectively minimize the reflection of ultraviolet rays, which come from behind the line of sight, as well as ultraviolet rays reflected from the facial skin, on the opposite surface of the lens, and it is also possible to decrease the total amount of ultraviolet rays which enters the eye interior. As a result, it is possible to effectively protect eyes from ultraviolet rays.

[0037]

Further, by forming a reflection preventing layer employing inorganic materials, it is possible to constitute

the reflection preventing layer into a very dense structure, whereby it is possible to provide high surface hardness as well as excellent durability to eyeglass lenses.

[0038]

Still further, by regulating the surface resistivity of the reflection preventing layer to no more than $1 \text{ M}\Omega/\text{cm}^2$, it is possible to result in excellent antistatic effects, whereby it is possible to minimize the adhesion of dust and the like on the surface of eyeglass lenses.

[0039]

In the eyeglass lens of the present invention, layers having various optical functions such as, for example, an ultraviolet reflecting layer, an ultraviolet absorbing layer, and the like, may be provided on the surface opposite the surface of the object side of the lens main body, namely the front surface of the lens.

[0040]

[EXAMPLES]

Examples of the present invention will now be specifically described. However, the present invention is not limited to these examples.

[0041]

<Method for Forming Layers>

In the present examples, as described below, layers are formed employing a vacuum deposition method along with an ion plating method.

[0042]

When the layer comprised of the materials, shown in Table 1 below, was formed, the vacuum deposition method was employed. Employed as deposition materials were the materials. Oxygen gas was introduced at a pressure shown in the central column and the deposition rate was regulated to the values in the right column so that formed layers were obtained with desired physical properties.

Herein, the degree of vacuum at the beginning of deposition was set at 1×10^{-3} Pa. The base material heating temperature was set at 350 °C. in the case of glass, and at 70 °C in the case of plastics. Further, when a metallic layer was formed, no gas was introduced.

[0043]

Table 1

Deposition Material	Inlet Gas Pressure (in Pa)	Deposition Rate (in Å/second)
Titanium Oxide (TiO_2)	25×10^{-2}	3
Hafnium oxide (HfO_2)	15×10^{-2}	4
Zirconium Oxide (ZrO_2)	15×10^{-2}	4
Tantalum Oxide (Ta_2O_5)	15×10^{-2}	4
Yttrium Oxide (Y_2O_3)	15×10^{-2}	5
Aluminum Oxide (Al_2O_3)	15×10^{-2}	5
Silicon Oxide (SiO_2)	1×10^{-2} to 2×10^{-2}	5 to 20
Magnesium Fluoride (MgF_2)	not introduced	10
Silver (Ag)	not introduced	4

[0044]

An electrically conductive transparent layer was formed employing high frequency discharge ion plating under conditions, as described below, for example, while a mixture consisting of indium metal and tin metal, as the deposition material, was evaporated under vacuum. Herein, the deposition materials were regulated so that the content ratio of tin in the formed electrically conductive transparent layer was from 3 to 10 percent by weight.

Inlet oxygen gas pressure: 25×10^{-2} Pa

Deposition rate: 3 Å/second

RF discharge power: 500 W

Incidentally, the "RF" refers to high frequency of no more than 1 GHz.

[0045]

<Measurement Methods>

(1) Spectral Transmittance

Spectral transmittance was measured employing Spectrophotometer "U-4000" (manufactured by Hitachi Seisakusho). Further, luminous transmittance was calculated employing measured spectral transmittance.

(2) Spectral Reflectance

Spectral reflectance was measured employing a 5° specular reflection apparatus of Spectrophotometer "U-4000" (manufactured by Hitachi Seisakusho). Further, samples having curvature such as, for example, lenses, and the like, were measured as follows. Measurement was carried out employing a Microscopic Spectrophotometer "USPM" (manufactured by Olympus Kogaku) equipped with a diaphragm in which a focal point was formed on the surface to be measured, and light rays reflected on the other surface was eliminated.

(3) Absorption Coefficient

Absorption coefficient was obtained based on the formula below, utilizing the spectral transmittance as well

as the spectral reflectance obtained in (1) and (2) previously described.

Absorption = $100 - (\text{spectral reflectance} + \text{spectral transmittance})$ (in percent)

[0046]

(4) Refractive Index

The refractive index of a single layer formed on a test piece (a glass base material) under the same conditions as those of previously described deposition was measured employing a Spectral Ellipsometer "VASE" (manufactured by JA Uram Co.).

[0047]

(5) Surface Resistivity

Surface resistivity was measured employing a 4-End Needle Probe (manufactured by Kyowa Riken). On the other hand, high surface resistivity was measured employing an Ultra Insulation Meter "SM-10E" (manufactured by Toa Denpa Kogyo). In this case, samples were prepared by forming the same layer as examples on a test piece (glass base material).

[0048]

<Example 1>

After forming a sublayer (a hard coat layer) comprised of acryl based ultraviolet hardening resins on a base

material comprised of polycarbonate resins, a multilayer comprised of the 10-layer structure, as shown in Table 2 below, was formed on the sublayer, whereby an optical element was prepared. The spectral reflectance of the optical element was measured and the spectral reflectance curve, shown in Fig. 2, was obtained. Then, it was found that the multilayer possessed reflection preventing effects in a wide range, from the ultraviolet region through the visible region.

Further, in Table 2, the refractive index of each layer was a value in terms of intended wavelength λ_0 regarding a single layer formed employing the same conditions as the deposition conditions previously described, and each layer thickness was at the intended thickness.

[0049]

Table 2

Layer	Layer Material	Refractive Index at λ_0 ($\lambda_0 = 520$ nm)	Optical Layer Thickness (in nd/λ_0)
First Layer	SiO ₂	1.46	0.205
Second Layer	TiO ₂	2.27	0.074
Third Layer	SiO ₂	1.46	0.035
Fourth Layer	TiO ₂	2.27	0.240
Fifth Layer	Y ₂ O ₃	1.79	0.048
Sixth Layer	TiO ₂	2.27	0.074
Seventh Layer	Y ₂ O ₃	1.75	0.060
Eighth Layer	SiO ₂	1.46	0.059
Ninth Layer	TiO ₂	2.27	0.031
Tenth Layer	SiO ₂	1.46	0.411
Eleventh Layer	Substrate Layer	1.52	-
Base Plate	PC	1.58	-

[0050]

<Example 2>

A multilayer comprised of the 10-layer structure, as shown in Table 3 below, was formed on a base material comprised of glass (BK-7), whereby an optical element was prepared. The spectral reflectance of the optical element was measured and the spectral reflectance curve, shown in Fig. 3, was obtained. Then, it was found that the multilayer possessed reflection preventing effects in the wide range from the ultraviolet region through the visible region.

[0051]

Table 3

Layer	Layer Material	Refractive Index at λ_0 ($\lambda_0 = 520$ nm)	Optical Layer Thickness (in nd/λ_0)
First Layer	MgF ₂	1.38	0.202
Second Layer	TiO ₂	2.34	0.061
Third Layer	SiO ₂	1.46	0.043
Fourth Layer	TiO ₂	2.34	0.275
Fifth Layer	Y ₂ O ₃	1.79	0.028
Sixth Layer	TiO ₂	2.34	0.072
Seventh Layer	Y ₂ O ₃	1.79	0.088
Eighth Layer	SiO ₂	1.46	0.038
Ninth Layer	TiO ₂	2.34	0.027
Tenth Layer	SiO ₂	1.46	0.404
Base Plate	BK-7	1.52	-

[0052]

<Example 3>

A multilayer comprised of the 2-layer structure comprising a metallic layer comprised of silver as shown in Table 4 below, was formed on a base material comprised of polycarbonate resins, whereby an optical element was prepared. The spectral reflectance of the optical element was measured and the spectral reflectance curve, shown in Fig. 4, was obtained. Then, it was found that the multilayer possessed reflection preventing effects in the wide range from the ultraviolet region through the visible region. It was also found that the surface resistivity of the multilayer

was $1 \text{ k}\Omega/\text{cm}^2$, and in addition, excellent antistatic effects were exhibited.

[0053]

Table 4

Layer	Layer Material	Refractive Index at λ_0 ($\lambda_0 = \text{nm}$)	Layer Thickness (in Å)
First Layer	SiO ₂	1.46	470
Second Layer	Ag	-	32
Base Plate	PC	1.58	-

[0054]

<Example 4>

After forming a sublayer (a hard coat layer) comprised of acryl based ultraviolet hardening resins on norbornane based resin A, a multilayer comprised of the 6-layer structure comprising an electrically conductive transparent layer comprised of ITO, as shown in Table 5 below, was formed on the sublayer, whereby an optical element was prepared. The reflectance of the optical element was measured and the spectral reflectance curve shown in Fig. 5 was obtained. Then, it was found that the multilayer possessed reflection preventing effects in the wide range from the ultraviolet region through the visible region. It was also found that

the surface resistivity of the multilayer was $15 \text{ k}\Omega/\text{cm}^2$, and excellent antistatic effects were exhibited.

[0055]

Table 5

Layer	Layer Material	Refractive Index at λ_0 ($\lambda_0 = 510 \text{ nm}$)	Optical Layer Thickness (in nd/λ_0)
First Layer	SiO_2	1.46	0.200
Second Layer	HfO_2	1.95	0.202
Third Layer	ITO	2.06	0.080
Fourth Layer	HfO_2	1.95	0.083
Fifth Layer	Y_2O_3	1.76	0.160
Sixth Layer	SiO_2	1.46	0.409
Seventh Layer	Substrate Layer	1.49	-
Base Plate	Resin A	1.52	-

[0056]

<Example 5>

After forming a sublayer (a hard coat layer) comprised of silicone based thermohardening resins on one surface which became the surface of the image side (the surface on the eye side) of the base material for eyeglasses comprised of urethane based resin B comprising UV absorbers which absorb ultraviolet rays at wavelengths of from 280 to 400 nm in a ratio of 100 percent, a multilayer comprised of the 5-layer structure, comprising an electrically conductive transparent layer comprised of ITO, as shown in Table 6 below, was formed

on the sublayer. Further, a multilayer comprised of the 5-layer structure, as shown in Table 7 below, was formed on the surface which became the surface of the object side opposite the surface on which the multilayer had been formed, whereby eyeglass lenses were prepared.

The reflectance of the surface of the image side (the surface of the eye side) was measured and the spectral reflectance curve shown in Fig. 6 was obtained. Then, it was found that the multilayer possessed reflection preventing effects in a wide range from the ultraviolet region through the visible region. It was also found that the surface resistivity of the multilayer was $60 \Omega/\text{cm}^2$, and excellent antistatic effects were exhibited.

Further, the reflectance of the surface of the object side of this optical element was measured and the spectral reflectance curve, shown in Fig. 7, was obtained. Then, it was found that the multilayer possessed high reflection preventing effects in the ultraviolet region, especially in the deep ultraviolet region (the UV-B region).

[0057]

Table 6

Layer	Layer Material	Refractive Index at λ_0 ($\lambda_0 = 520$ nm)	Optical Layer Thickness (in nd/λ_0)
First Layer	SiO ₂	1.46	0.188
Second Layer	HfO ₂	1.95	0.140
Third Layer	ITO	2.06	0.250
Fourth Layer	Y ₂ O ₃	1.75	0.174
Fifth Layer	SiO ₂	1.46	0.398
Sixth Layer	Substrate Layer	1.52	-
Base Plate	Resin B	1.60	-

[0058]

Table 7

Layer	Layer Material	Refractive Index at λ_0 ($\lambda_0 = 520$ nm)	Optical Layer Thickness (in nd/λ_0)
First Layer	SiO ₂	1.46	0.240
Second Layer	ZrO ₂	2.06	0.504
Third Layer	SiO ₂	1.46	0.081
Fourth Layer	ZrO ₂	2.06	0.062
Fifth Layer	SiO ₂	1.46	0.062
Sixth Layer	Substrate Layer	1.55	-
Base Plate	Resin B	1.58	-

[0059]

<Example 6>

After forming a sublayer (a hard coat layer) comprised of silicone based thermohardening resins on one surface, which became the surface of the image side (the surface on

the eye side) of the base material for eyeglasses comprised of urethane based thermohardening resin B comprising UV absorbers, a multilayer comprised of the 5-layer structure, comprising an ITO layer (an electrically conductive transparent layer), as shown in Table 8 below, was formed on the sublayer. Further, a multilayer comprised of the 5-layer structure, as shown in Table 7, was formed in the same manner as Example 5 on the surface which became the surface of the object side opposite the surface on which the multilayer had been formed, whereby eyeglass lenses were prepared.

The reflectance of the surface of the image side (the surface of the eye side) of the eyeglass lens was measured and the spectral reflectance curve, shown in Fig. 8, was obtained. Then, it was found that the multilayer possessed reflection preventing effects in a wide range from the ultraviolet region through the visible region. It was also found that the surface resistivity of the multilayer was $45 \Omega/\text{cm}^2$, and excellent antistatic effects were exhibited.

Further, the reflectance of the surface of the object side of this optical element was measured. Then, it was found that the multilayer possessed high reflection preventing effects in the ultraviolet region, especially in the deep ultraviolet region (the UV-B region).

[0060]

Table 8

Layer	Layer Material	Refractive Index at λ_0 ($\lambda_0 = 510$ nm)	Optical Layer Thickness (in nd/λ_0)
First Layer	SiO ₂	1.46	0.184
Second Layer	Ta ₂ O ₅	2.09	0.048
Third Layer	Al ₂ O ₃	1.64	0.051
Fourth Layer	ITO	2.06	0.302
Fifth Layer	Al ₂ O ₃	1.64	0.200
Sixth Layer	SiO ₂	1.46	0.345
Seventh Layer	Substrate Layer	1.52	-
Base Plate	Resin B	1.60	-

[0061]

As noted above, it was confirmed that the optical elements prepared in Examples 1 and 2 exhibited reflectance of no more than approximately 1 percent for all light rays having a wavelength in the region of from 280 to 700 nm on the surface of the formed multilayer, and possessed an excellent reflection preventing function.

[0062]

It was confirmed that optical elements prepared in Examples 3 and 4 exhibited reflectance of nearly no more than approximately 2 percent for all light rays having a wavelength in the range of from 280 to 700 nm on the surface of the formed multilayer, and though the resulting

reflectance was greater than that of optical elements prepared in Examples 1 and 2, they possessed a sufficient reflection preventing function as well as an excellent antistatic function and electromagnetic wave decreasing function.

[0063]

It was confirmed that the optical element prepared in Example 5 exhibited reflectance of no more than 2 percent for the entire light rays having a wavelength in the region of from 280 to 700 nm on the surface which became the surface of the image side, and exhibited sufficiently high reflectance for ultraviolet rays on the surface of the object side, and possessed excellent reflection preventing function for light rays incident from the surface of the image side of the optical element, and possessed an excellent reflection function against ultraviolet rays incident from the surface of the object side.

Further, when the optical element is employed, for example, as eyeglass lenses, the base material possesses a high ultraviolet absorbing function. As a result, by combining the ultraviolet reflection preventing function and ultraviolet reflection function of the layer previously described, it is possible to greatly minimize the

introduction of ultraviolet rays into the eye interior. Namely, it is possible to reflect the ultraviolet rays incident to the surface of the eye side (the front surface of the lens) from the atmosphere side on the surface of the eye side, utilizing the reflection preventing function of the layer, whereby it is possible to minimize the entrance of the ultraviolet rays into the eye interior. Further, by utilizing the ultraviolet absorbing function due to lens base materials, ultraviolet rays incident from the surface of the eye side are reflected on the surface of (the front surface of the lens) of the side opposite the eye side, whereby ultraviolet rays which come from the surface of the eye side are assuredly minimized. Thus it is possible to minimize ultraviolet rays into the interior of eyes.

[0064]

The optical element prepared in Example 6 results in high reflectance against some light rays having a wavelength in the region of from 280 to 700 nm from the surface of the formed multilayer. However, the resulting phenomena are caused as follows: in order to decrease reflection against ultraviolet rays in the shorter wavelength region, which has been noted to tend to be highly injurious to human eyes, as

well as to enhance actual viewing, reflectance of blue light is somewhat increased.

Further, it was confirmed that the optical element possessed an excellent electromagnetic wave decreasing function.

[0065]

[EFFECT OF THE INVENTION]

According to the optical element of the present invention, reflectance, on the surface of the formed layer, of the entire light rays having wavelengths in the specified region becomes smaller than the reflectance on the surface of the base material itself. As a result, it is possible to decrease adverse effects due to the reflected light rays on the surface.

According to the eyeglass lens of the present invention, reflection of ultraviolet rays coming from behind the line of sight is assuredly minimized on the back surface of the lens. Thus, it is possible to minimize the entrance of the ultraviolet rays into the eye interior and consequently due to this, it is possible reduce the total amount of ultraviolet rays which enter the eye interior, and it is therefore possible to protect eyes from ultraviolet rays.

[BRIEF DESCRIPTION OF THE DRAWINGS]

Fig. 1 is a cross-sectional view showing one example of the constitution of the optical element of the present invention.

Fig. 2 is a spectral reflectance curve of the optical element prepared in Example 1.

Fig. 3 is a spectral reflectance curve of the optical element prepared in Example 2.

Fig. 4 is a spectral reflectance curve of the optical element prepared in Example 3.

Fig. 5 is a spectral reflectance curve of the optical element prepared in Example 4.

Fig. 6 is a spectral reflectance curve of the surface of the image side of the optical element prepared in Example 5.

Fig. 7 is a spectral reflectance curve of the surface of the object side of the optical element prepared in Example 5.

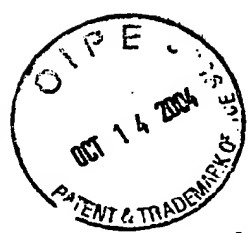
Fig. 8 is a spectral reflectance curve of the optical element prepared in Example 6.

[Explanation of notation]

10 optical element

10A image side surface

- 10B object side surface
- 11 base material
- 12 layer (antireflection layer)



[NAME OF THE DOCUMENT] Drawings

FIG. 1

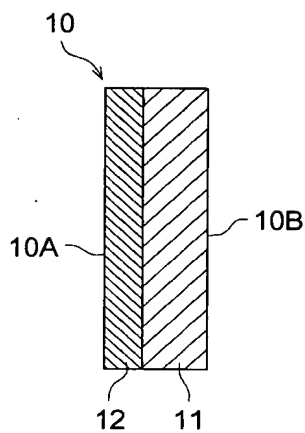
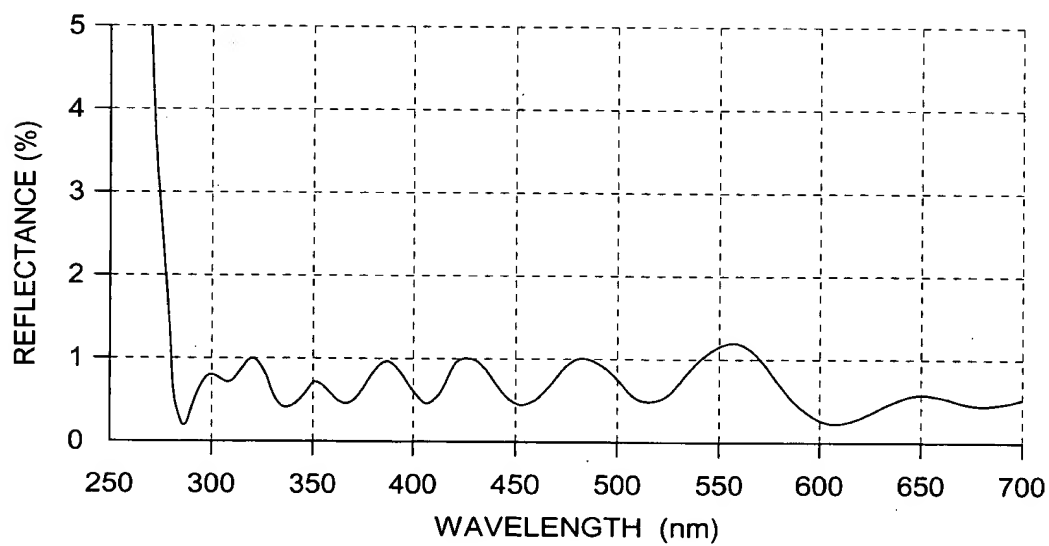


FIG. 2





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FIG. 3

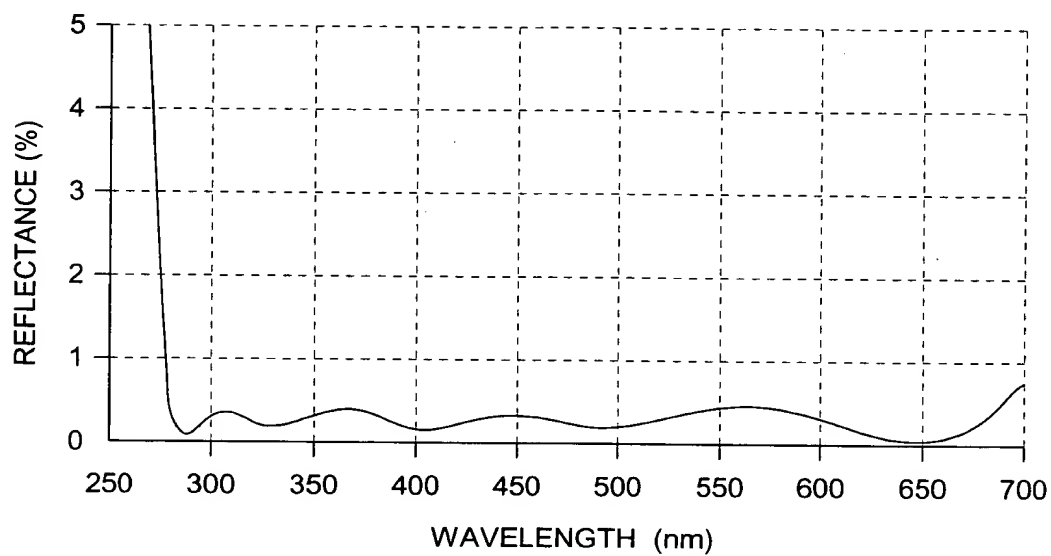
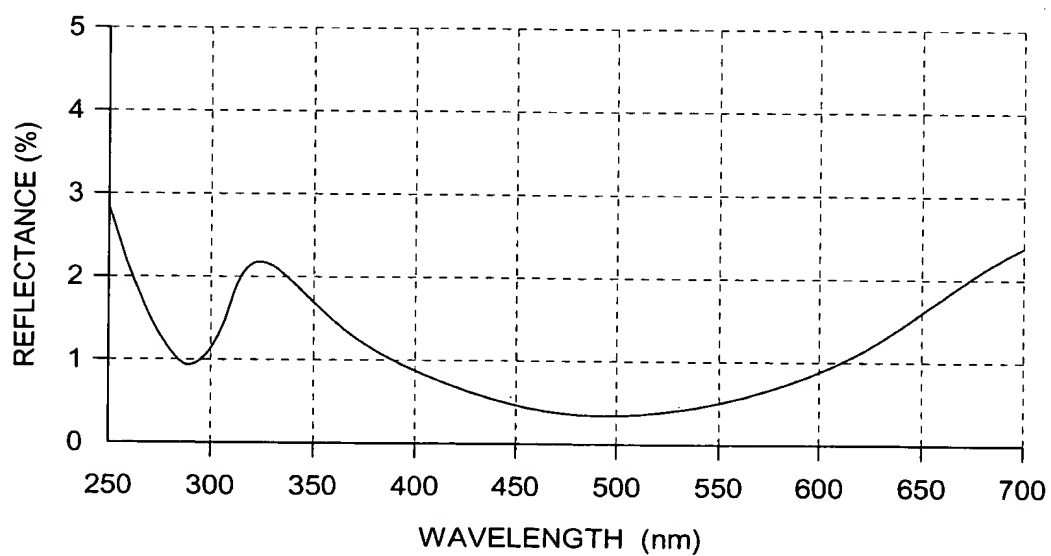


FIG. 4





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12-216254

FIG. 5

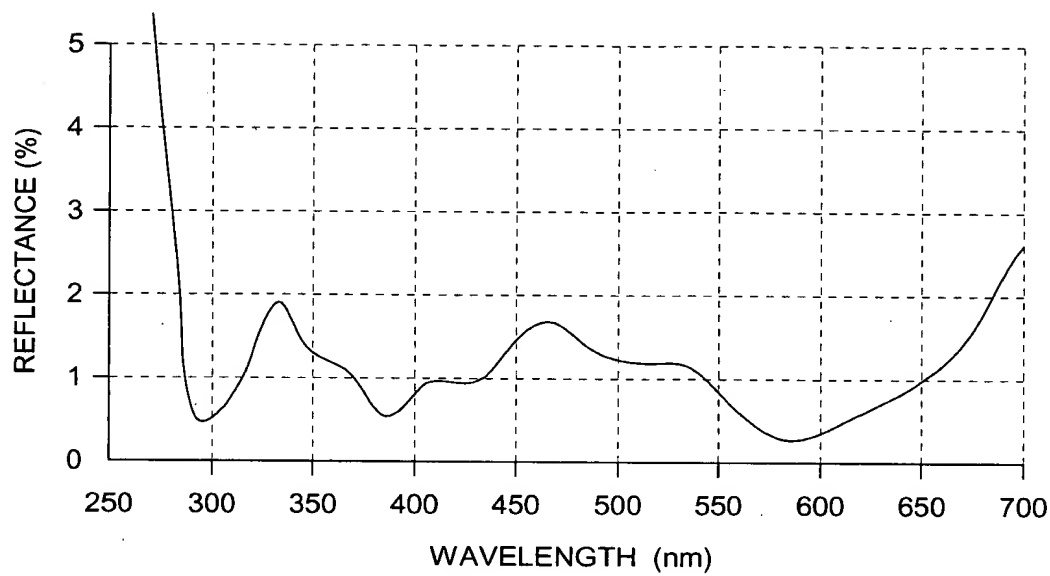


FIG. 6

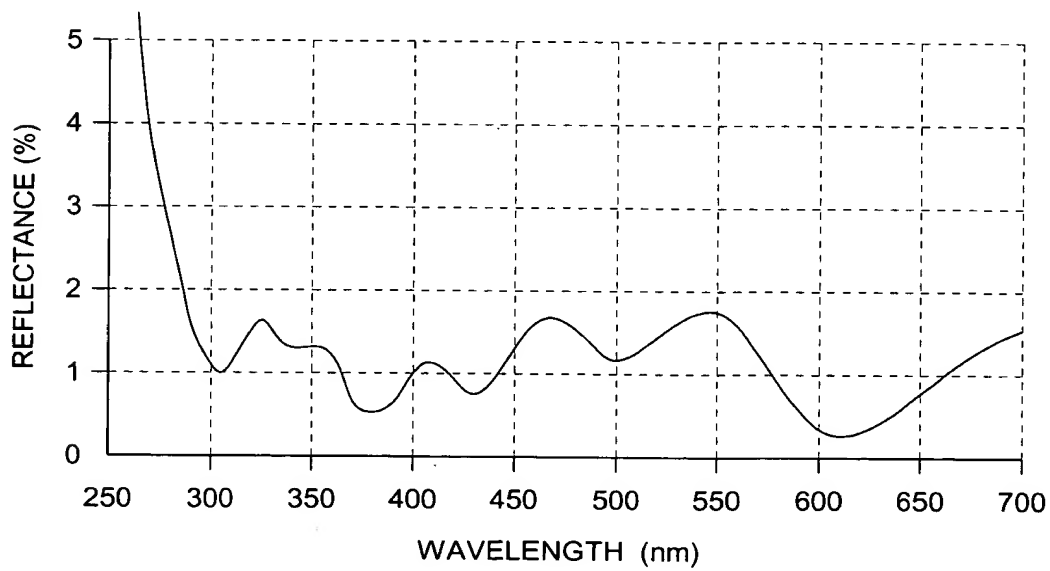




FIG. 7

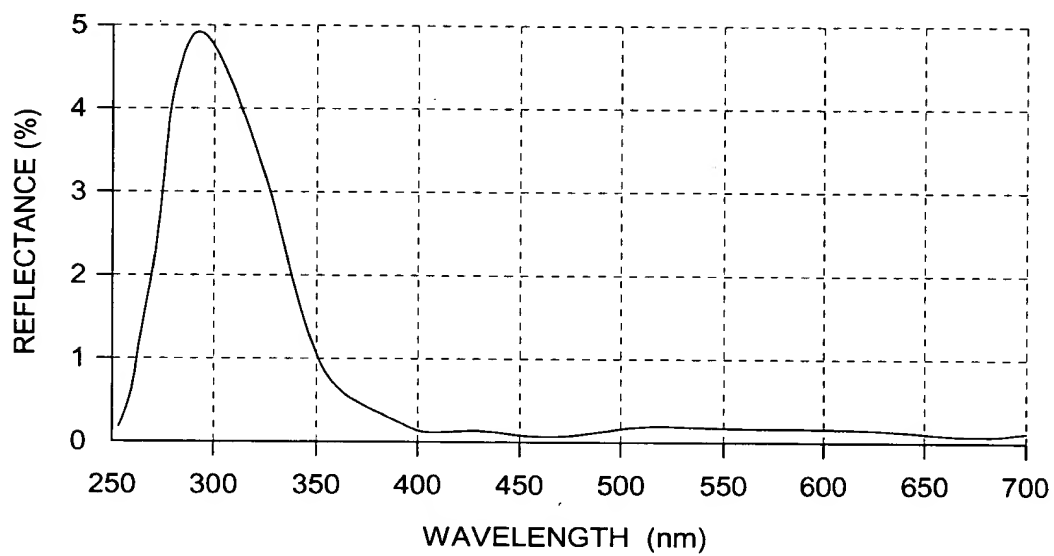
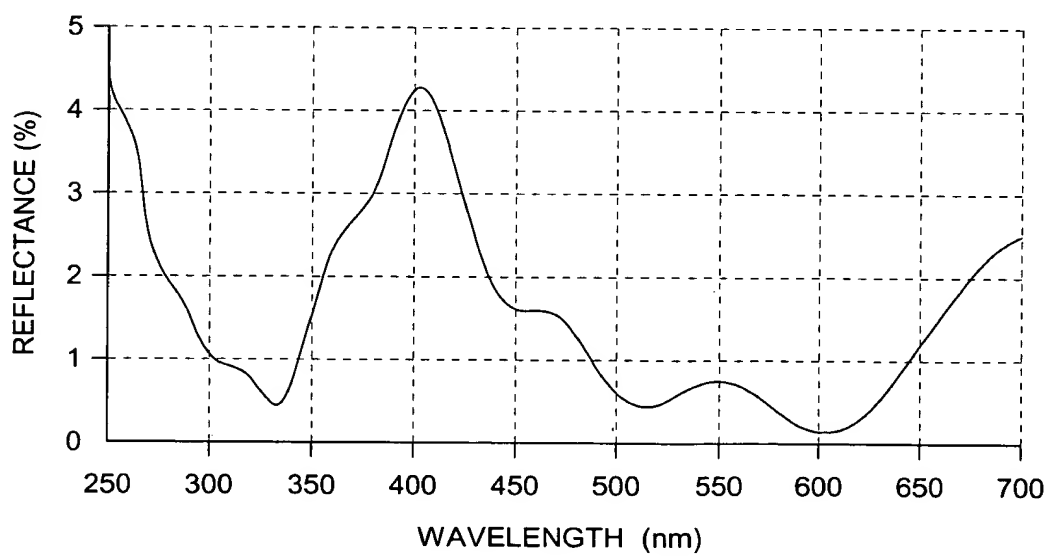


FIG. 8





[NAME OF DOCUMENT] ABSTRACT

[ABSTRACT]

[OBJECTIVE] To provide an optical element comprising a layer capable of exhibiting a reflection preventing effect against all light rays within a range from a ultraviolet ray region to a visible light region and capable of decreasing injurious effects due to the light rays which is reflected from a surface and to provide an eyeglass lens capable of effectively protecting eyes from ultraviolet rays.

[SOLVING MEANS] In an optical element comprised of a base material and a layer which is formed on at least one part of the surface of the base material, the layer is substantially comprised of an inorganic material, and the reflectance of the entire light rays in the wavelength region of from 280 to 800 nm. A surface resistance of the layer is $1 \text{ M}\Omega/\text{cm}^2$ or less, and the layer is formed on an image side-entire surface of the lens. An eyeglass lens is formed by the optical element of the present invention.

[SELECTION OF DRAWINGS] None